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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/800,219	03/12/2004	Nadya G. Strelkova	03-2396 8549 EXAMINER	
24319	7590 12/01/2005			
LSI LOGIC CORPORATION 1621 BARBER LANE			LAM, NELSON C	
MS: D-106	EK LANE		ART UNIT	PAPER NUMBER
MILPITAS,	CA 95035		2825	
			DATE MAILED: 12/01/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	
Office Action Symmony	10/800,219	STRELKOVA ET AL.	
Office Action Summary	Examiner	Art Unit	
	Nelson Lam	2825	
The MAILING DATE of this communication apperiod for Reply	opears on the cover sheet with	1 the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING [- Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory perior - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mailine earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNIC .136(a). In no event, however, may a repl d will apply and will expire SIX (6) MONT tte, cause the application to become ABA	ATION. ply be timely filed HS from the mailing date of this communication. UNDONED (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on 12	<u>March 2004</u> .		
, - ,	is action is non-final.		
3) Since this application is in condition for allow			
closed in accordance with the practice under	Ex parte Quayle, 1935 C.D.	11, 453 O.G. 213.	
Disposition of Claims			
4) Claim(s) 1-18 is/are pending in the application	n.		
4a) Of the above claim(s) is/are withdr	awn from consideration.		
5) Claim(s) is/are allowed.			
6) Claim(s) 1-18 is/are rejected.			
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and	or election requirement.		
	, 0, 0, 0, 0		
Application Papers			
9) The specification is objected to by the Examin		- de de boetha Francisca	
10)⊠ The drawing(s) filed on 12 March 2004 is/are			
Applicant may not request that any objection to the Replacement drawing sheet(s) including the corre			
11) The oath or declaration is objected to by the			
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign	gn priority under 35 U.S.C. §	119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of: 1. ☐ Certified copies of the priority docume	nts have been received		
2. Certified copies of the priority docume		oplication No.	
3. Copies of the certified copies of the pr			
application from the International Bure			
* See the attached detailed Office action for a li	st of the certified copies not	received.	
		C.	
Attachment(s)		(***	
1) Notice of References Cited (PTO-892)		ummary (PTO-413) s)/Mail Date	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0		offormal Patent Application (PTO-152)	
Paper No(s)/Mail Date	6) 🔲 Other:	<u>_</u> .	

DETAILED ACTION

1. Responsive to communication of 03/12/2004. Application 10/800,219 has been examined. In the examination of 10/800,219, claims 1-18 are pending.

Specification

2. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed. Claims are directed to a method and apparatus of verifying reticle latent image sensitivity. Applicants should also refrain from using acronyms in their titles (e.g. ret).

The disclosure is objected to because of the following informalities: The meaning of the terms "CD", "DI", "DICD" and "FICD" need to be stated.

Appropriate correction is required.

Drawings

3. Figures 1-3 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g). Corrected drawings in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

Claim Objections

4. Claim 3 is objected to because of the following informalities: the term "and/or" needs to be restated using "and" else "or". Appropriate correction is required.

Claim Rejections - 35 USC § 102

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 6. Claims 1-2 and 6 are rejected under 35 U.S.C. 102(e) as being anticipated by Weed (US Patent No. 6,658,640).

As per claim 1, Weed discloses a method for verifying reticle enhancement technique latent image sensitivity to mask manufacturing errors, said method comprising: revising a polygon based on mask CD distributions to provide a virtual statistical mask (Fig. 1; col. 1, line 22-38; col. 6, line 9-34; col. 7, line 19-31); obtaining response function statistical parameters based on the virtual mask image (Fig. 2; col. 4, line 38-60); and comparing the statistical parameters to design rule requirements (Fig. 4, #425; col. 8, line 53-63).

As per **claim 2**, Weed discloses a method as recited in claim 1, further comprising forming an simulated image of the virtual mask (Fig. 3, #303; col. 4, line 61-67; col. 5, line 1-9).

As per claim 6, Weed discloses a method as recited in claim 1, further comprising obtaining the virtual mask by using mask CD distribution to induce statistical variations to layout which have passed through an OPC procedure (Fig. 1; col. 1, line 22-38; col. 6, line 9-34; col. 7, line 19-31).

Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. Claims 3-5 and 7-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Weed in view of Mansfield et al. (US Patent No. 6,421,820), Weed discloses a method of optimizing a mask for wafer fabrication. However, Weed does not disclose mask optimization using aerial images, moving fragments of a polygon and re-sizing primitives. Mansfield also discloses a method of optimizing a mask for wafer fabrication that includes using aerial images, moving fragments of a polygon and re-sizing primitives that Weed does not disclose. Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to include using aerial images, moving fragments of a polygon and re-sizing primitives in the method of Mansfield in the method of Weed since including these features would represent an improvement in the method of Weed (col. 4, line 30-37).

As per claim 3, Mansfield discloses a method as recited in claim 2, further comprising calculating response functions based on the aerial and/or latent image simulation (Fig. 4B; col. 4, line 30-38; col. 4, line 66-67; col. 5, line 1-4).

As per **claim 4**, Weed discloses a method as recited in claim 3, further comprising collecting measurements and calculating statistical parameters based on the response functions (Fig. 3, #312; col. 5, line 52-59; col. 6, line 1-9).

As per **claim 5**, Weed discloses a method as recited in claim 4, further comprising comparing the statistical parameters with design rule requirements (Fig. 4, #425; col. 8, line 53-67; col. 9, line 1-27).

As per claim 7, Mansfield discloses a method as recited in claim 6, further comprising at least one of moving fragments of a polygon and re-sizing primitives (col. 3, line 1-9; Fig. 3A, 3B, 4A, 4B; Fig. 5; col. 4, line 52-58; col. 5, line 5-10; col. 5, line 19-23; col. 4, line 22-29).

As per claim 8, Mansfield discloses a method as recited in claim 6, further comprising moving fragments of a polygon based on a randomly generated number from mask CD distribution (Fig. 6; col. 5, line 24-44).

As per claim 9, Weed discloses a method as recited in claim 6, further comprising re-sizing primitives depending on mask CD distribution (Weed: col. 2, line 4-51), (Mansfield: col. 3, line 1-9; Fig. 3A, 3B, 4A, 4B; Fig. 5; col. 4, line 52-58; col. 5, line 5-10; col. 5, line 19-23; col. 4, line 22-29).

9. Claim 10 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Mansfield et al. in view of Balasinski et al. (US Patent No. 6,562,638). Mansfield

discloses a method of optimizing a wafer mask by adjusting drawing features of a mask pattern. However, Mansfield does not discloses a method of predicting yield. Balasinski also discloses a method of optimizing a mask by adjusting drawing features of a mask pattern that includes a method of predicting yield that Mansfield does not disclose. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include the method of predicting yield of Balasinski to the method of Mansfield since this would represent an improvement in the invention of Mansfield (col. 7, line 14-21).

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As per claim 10, Balasinski discloses a yield prediction tool from mask quality 10. specifications (Abstract; Fig. 24; col. 6, line 45-61; col. 7, line 52-64), said tool comprising means from revising a polygon based on mask CD distributions to provide a virtual mask (Weed: Fig. 1; col. 1, line 22-38; col. 6, line 9-34; col. 7, line 19-31), means for obtaining statistical parameters based on the virtual mask imaging (Weed: Fig. 2; col. 4, line 38-60); and means from comparing the statistical parameters to design rule requirements (Weed: Fig. 4, #425; col. 8, line 53-63).

As per claim 11, Mansfield discloses a tool as recited in claim 10, further comprising means from simulating an aerial and/or latent image of the virtual mask (Fig. 4B; col. 4, line 30-38; col. 4, line 66-67; col. 5, line 1-4).

Claims 12-18 are rejected under 35 U.S.C. 103(a) as being unpatentable over 11. Mansfield et al. in view of Balasinski et al. in further view of Weed. Mansfield and Balasinski discloses a method of optimizing a mask by adjusting drawing features of a mask pattern. However, Mansfield and Balasinski do not disclose optimizing a mask that includes using CD distributions and statistical parameters. Weed also discloses a method of optimizing a mask by adjusting drawing features of a mask pattern that includes using CD distributions and statistical parameters that Mansfield and Blasinski do not disclose. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include the method of using CD distributions and statistical parameters of Weed in the method of Mansfield and Balasinski since this would represent an improvement in the invention of Mansfield and Balasinski (Mansfield: col. 7, line 14-21; Balasinski: col. 9, line 6-10).

As per **claim 12**, Weed discloses a tool as recited in claim 11, further comprising means for calculating response functions based on the simulated image (Fig. 3, #312; col. 5, line 52-59; col. 6, line 1-9).

As per **claim 13**, Weed discloses a tool as recited in claim 12, further comprising means for collecting measurements and calculating statistical parameters based on the response functions (Fig. 3, #312; col. 5, line 52-59; col. 6, line 1-9).

As per **claim 14**, Weed discloses a tool as recited in claim 13, further comprising means for comparing the statistical parameters with design rule requirements (Fig. 4, #425; col. 8, line 53-63).

As per claim 15, Weed discloses a tool as recited in claim 10, further comprising means for obtaining the virtual mask by using mask CD distribution to statistically vary layouts which have passed through an OPC procedure (Fig. 1; col. 1, line 22-38; col. 6, line 9-34; col. 7, line 19-31).

As per claim 16, Mansfield discloses a tool as recited in claim 15, further comprising means for at least one of moving fragments of a polygon and re-sizing primitives (col. 3, line 1-9; Fig. 3A, 3B, 4A, 4B; Fig. 5; col. 4, line 52-58; col. 5, line 5-10; col. 5, line 19-23; col. 4, line 22-29).

As per claim 17, Mansfield discloses a tool as recited in claim 15, further comprising means for moving fragments of a polygon based on a randomly generated number from mask CD distribution (Fig. 6; col. 5, line 24-44).

As per claim 18, Weed discloses a tool as recited in claim 15, further comprising means for re-sizing primitives depending on mask CD distribution (col. 3, line 1-9; Fig. 3A, 3B, 4A, 4B; Fig. 5; col. 4, line 52-58; col. 5, line 5-10; col. 5, line 19-23; col. 4, line 22-29).

Conclusion

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nelson Lam whose telephone number is 571 272-8318. The examiner can normally be reached on 9am - 5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 10/800,219

Art Unit: 2825

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Nelson Lam

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Art Unit 2825

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